

IPW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:  
Chun-Chieh Lin

Serial No.: 10/749,273

Filed: December 29, 2003

For: SOI MOSFET WITH MULTI-SIDED  
SOURCE/DRAIN SILICIDE

§ Group Art Unit: 2826

§ Examiner: Mondt, Johannes P.

§ Confirmation No.: 8520

Mail Stop Amendment  
Commissioner of Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

Fee  
only

**AMENDMENT IN RESPONSE TO OFFICE ACTION MAILED MARCH 25, 2005**

**I. Introductory Comments**

The present paper is being submitted in response to the Office Action mailed March 25, 2005. No fees, including extension of time fees, are believed necessary for consideration of the present paper. However, if any fees are necessary, including extension of time fees, the extension of time is hereby requested, and the Commissioner is hereby authorized to charge any fees, including those for the extension of time, to Haynes and Boone, LLP's Deposit Account No. 08-1394.

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

04/26/2005 TLAURENC 00000006 081394 10749273

01 FC:1202 **Remarks/Arguments** begin on page 10 of this paper.